

The Technical Association of Refractories, Japan

Certified Reference Material Series for X-ray Fluorescence Analysis of Refractories

J R R M 7 0 1 (Alumina-Zirconia-Silica Refractory)

Results of Analyses

Unit : mass%

Constituent	SiO ₂	Al ₂ O ₃	Fe ₂ O ₃	TiO ₂	CaO	MgO	Na ₂ O	K ₂ O	Cr ₂ O ₃	ZrO ₂ (+HfO ₂)	HfO ₂	ZrO ₂ ^{*3}	Uncertified value		
													MnO	P ₂ O ₅	
Certified value	28.4 ₇	10.1 ₀	2.01 ₀	4.96 ₅	2.07 ₅	0.47 ₇	1.84 ₇	0.02 ₄	1.01 ₁	48.9 ₅	0.85 ₀	48.1 ₁	0.00 ₇	0.02 ₇	
Laboratories	L ₁	28.2 _{8 p}	10.1 _{5 e}	2.01 _{5 i}	4.96 _{5 i}	2.09 _{1 i}	0.45 _{5 i}	1.86 _{5 a}	0.03 _{1 a}	1.00 _{0 i}	48.6 _{0 m}	0.83 _{0 x}	—	0.00 _{5 i}	0.02 _{2 e}
	L ₂	28.4 _{1 p}	10.1 _{0 e}	2.03 _{4 e}	4.94 _{4 i}	2.05 _{1 i}	0.47 _{5 i}	1.84 _{2 i}	0.02 _{5 i}	0.98 _{0 i}	48.8 _{1 m}	0.83 _{7 i}	—	0.00 _{5 i}	0.03 _{7 e}
	L ₃	28.4 _{2 h}	10.3 ₀	1.98 _{0 e}	4.98 _{8 e}	2.08 _{1 a}	0.47 _{6 a}	1.84 _{2 a}	0.02 _{1 a}	0.99 _{2 a}	49.2 _{6 m}	0.82 _{7 x}	—	—	—
	L ₄	28.3 _{0 p}	10.0 _{2 e}	2.02 _{5 i}	4.96 _{1 i}	2.13 _{5 i}	0.50 _{5 i}	1.85 _{5 a}	0.02 _{6 a}	1.00 _{7 i}	49.1 _{5 m}	0.85 _{5 i}	—	0.00 _{9 i}	—
	L ₅	28.6 _{0 h}	10.0 _{0 e}	1.99 _{0 e}	4.95 _{3 e}	2.00 _{5 a}	0.48 _{3 a}	1.83 _{5 a}	0.01 _{9 a}	1.05 _{2 a}	48.9 _{3 m}	0.85 _{3 x}	—	0.00 _{1 a}	0.02 _{2 e}
	L ₆	28.5 _{3 h}	10.0 _{0 e}	2.02 _{5 e}	4.98 _{5 i}	2.09 _{1 i}	0.48 _{7 i}	1.86 _{2 a}	0.02 _{4 a}	1.01 _{1 i}	48.7 _{2 m}	0.87 _{0 i}	—	0.00 _{5 i}	0.03 _{0 e}
	L ₇	28.6 _{7 p}	10.0 _{0 e}	1.98 _{1 e}	4.94 _{1 e}	2.04 _{1 a}	0.44 _{6 a}	1.80 _{0 a}	0.02 _{0 a}	1.03 _{0 a}	49.0 _{0 g}	0.86 _{5 i}	—	—	—
	L ₈	28.5 _{0 p}	10.0 _{4 e}	2.00 _{5 e}	4.97 _{0 e}	2.09 _{1 a}	0.48 _{6 a}	1.86 _{0 a}	0.02 _{2 a}	0.98 _{5 a}	49.1 _{6 m}	0.86 _{5 x}	—	0.00 _{7 e}	0.02 _{2 e}
Average (\bar{X})	28.46 ₅	10.10 ₀	2.009 ₅	4.965 ₁	2.075 ₃	0.476 ₅	1.847 ₄	0.023 ₆	1.010 ₅	48.95 ₆	0.850 ₄	48.10 ₆	0.007 ₀	0.026 ₆	
Standard deviation (Reproducibility)	$s_{\bar{x}}$	0.13 ₀	0.09 ₅	0.020 ₆	0.019 ₂	0.039 ₂	0.018 ₄	0.019 ₆	0.003 ₅	0.023 ₆	0.21 ₀	0.017 ₀	—	0.001 ₇	0.006 ₅
deviation (Reproducibility without laboratories)	$s_{1(T)}^{*1}$	0.10 ₀	0.08 ₃	0.010 ₁	0.008 ₅	0.011 ₂	0.005 ₅	0.019 ₅	0.002 ₂	0.006 ₅	0.12 ₅	0.007 ₀	—	0.000 ₅	0.005 ₇
Uncertainty C (95%) ^{*2}	0.1 ₁	0.0 ₅	0.01 ₇	0.01 ₅	0.03 ₃	0.01 ₅	0.01 ₅	0.00 ₃	0.02 ₀	0.1 ₅	0.01 ₄	0.1 ₅ ^{*4}	0.00 ₂	0.00 ₅	

(Note) * 1 $s_{1(T)}$ is intermediate precision without a time condition.* 2 The half-width confidence interval C (95%) = $t_{l-1,0.05} \times s_{\bar{x}} / \sqrt{l}$ (l = number of laboratories)* 3 $ZrO_2 = ZrO_2(+HfO_2) - HfO_2$ * 4 $s_{\bar{x}ZrO_2} = \sqrt{\left(s_{\bar{x}ZrO_2(+HfO_2)}\right)^2 + \left(s_{\bar{x}HfO_2}\right)^2}$

(1) List of laboratories : Kurosaki Corporation, Kawasaki Refractories Co.,Ltd., Yotai Refractories Co.,Ltd., Asahi Glass Co.,Ltd., Harima Ceramic Co.,Ltd., Shinagawa Refractories Co.,Ltd., Toshiba Ceramics Co.,Ltd., Toshiba Monofrax Co.,Ltd.

(2) Analytical techniques : JIS R 2013(Method for chemical analysis of refractory containing alumina, zirconia and silica) a:AAS, c:colorimetry, e:Ionexchange-chelatometry, f:flametry, g:Cupfron Gravimetry, h:dehydration+colorimetry, i:ICP-AES, m:Mandelic acid Gravimetry, p:picoagulation+colorimetry, v:Cupfron Separation-chelatometry, x:XRF

(3) Analytical values : Each value is the average of two values obtained by two measurements on different days. These analysis values are shown converted into LOI (Loss on ignition) component free values from the February 22, 2008 v20080222 version on.

(4) Outlier tests were carried out by Grubbs test. The samples rejected by Grubbs tests were discussed in view of analytical techniques and it was determined whether the outliers should be adopted or not.

(5) Date of preparation : June, 1996

Prepared, and Values given and certified by

The Technical Association of Refractories, Japan
 New Ginza Bldg., 3-13, Ginza 7-chome, Chuo-ku, Tokyo 104-0061, Japan
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The Technical Association of Refractories, Japan

Certified Reference Material Series for X-ray Fluorescence Analysis of Refractories

J R R M 7 0 2 (Alumina-Zirconia-Silica Refractory)

Results of Analyses

Unit : mass%

Constituent	SiO ₂	Al ₂ O ₃	Fe ₂ O ₃	TiO ₂	CaO	MgO	Na ₂ O	K ₂ O	Cr ₂ O ₃	ZrO ₂ (+HfO ₂)	HfO ₂	ZrO ₂ *3	Uncertified value		
													MnO	P ₂ O ₅	
Certified value	10.0 ₁	38.2 ₁	0.37 ₄	0.21 ₁	1.55 ₃	1.98 ₂	2.02 ₇	0.58 ₃	0.11 ₁	44.7 ₁	2.09 ₆	42.6 ₂	0.00 ₄	0.02 ₈	
Laboratories	L ₁	9.96 _{0 p}	38.3 _{1 o}	0.36 _{7 i}	0.20 _{4 i}	1.56 _{7 i}	1.99 _{3 i}	2.04 _{6 n}	0.58 _{1 n}	0.12 _{0 i}	44.7 _{2 m}	2.06 _{1 x}	—	0.00 _{4 i}	0.02 _{7 o}
	L ₂	9.96 _{7 p}	38.0 _{4 n}	0.37 _{6 o}	0.21 _{0 i}	1.53 _{6 i}	1.94 _{9 i}	2.03 _{5 f}	0.58 _{7 f}	0.11 _{4 i}	44.7 _{5 m}	2.07 _{0 i}	—	0.00 _{4 i}	0.03 _{0 o}
	L ₃	10.1 _{6 h}	38.2 ₅	0.37 _{7 o}	0.19 _{3 o}	1.58 _{2 n}	2.00 _{2 n}	1.99 _{9 n}	0.56 _{4 n}	0.10 _{8 n}	44.8 _{2 m}	2.06 _{9 x}	—	—	—
	L ₄	9.92 _{9 p}	38.1 _{4 v}	0.37 _{1 i}	0.20 _{5 i}	1.56 _{2 i}	1.99 _{7 i}	2.04 _{3 n}	0.60 _{1 n}	0.11 _{1 i}	44.7 _{5 m}	2.12 _{1 i}	—	0.00 _{4 i}	—
	L ₅	9.99 _{5 h}	38.2 _{9 u}	0.37 _{5 o}	0.19 _{8 o}	1.54 _{8 n}	1.98 _{9 n}	2.03 _{9 n}	0.54 _{9 n}	0.10 _{5 n}	44.6 _{2 m}	2.03 _{5 x}	—	0.00 _{2 o}	0.02 _{7 o}
	L ₆	9.99 _{2 h}	38.1 _{6 n}	0.36 _{9 o}	0.22 _{1 o}	1.55 _{9 i}	1.98 _{7 i}	2.01 _{3 n}	0.57 _{9 n}	0.10 _{4 n}	44.5 _{1 m}	2.11 _{8 i}	—	0.00 _{4 i}	0.02 _{9 o}
	L ₇	10.1 _{6 p}	38.3 _{8 o}	0.38 _{3 o}	0.23 _{1 o}	1.54 _{4 n}	1.98 _{3 i}	2.01 _{7 n}	0.59 _{1 n}	0.11 _{2 n}	44.7 _{9 f}	2.10 _{7 i}	—	—	—
	L ₈	9.94 _{6 p}	38.1 _{4 v}	0.379	0.22 _{0 o}	1.54 _{2 n}	1.95 _{9 n}	2.02 _{7 n}	0.58 _{5 n}	0.11 _{2 n}	44.7 _{0 m}	2.13 _{8 x}	—	0.00 _{5 n}	0.02 _{6 o}
Average (\bar{X})	10.01 ₂	38.21 ₄	0.374 ₅	0.210 ₆	1.554 ₅	1.982 ₄	2.027 ₃	0.579 ₅	0.110 ₉	44.71 ₁	2.089 ₉	42.62 ₁	0.003 ₈	0.027 ₅	
Standard deviation (Reproducibility without laboratories)	$s_{\bar{x}}$	0.09 ₀	0.10 ₁	0.005 ₆	0.012 ₂	0.016 ₁	0.018 ₃	0.016 ₃	0.016 ₁	0.005 ₀	0.09 ₄	0.036 ₀	—	0.001 ₀	0.001 ₄
	$s_{I(T)}^{*1}$	0.05 ₇	0.07 ₉	0.007 ₆	0.003 ₄	0.011 ₅	0.011 ₉	0.017 ₅	0.012 ₂	0.002 ₄	0.10 ₅	0.009 ₃	—	0.000 ₈	0.001 ₃
Uncertainty C (95%) ^{*2}	0.0 ₈	0.0 ₈	0.00 ₅	0.01 ₀	0.01 ₃	0.01 ₅	0.01 ₄	0.01 ₃	0.00 ₄	0.0 ₈	0.03 ₀	0.0 ₈ ^{*4}	0.00 ₁	0.00 ₂	

(Note) *1 $s_{I(T)}$ is intermediate precision without a time condition.*3 $ZrO_2 = ZrO_2(+HfO_2) - HfO_2$ *2 The half-width confidence interval C (95%) = $t_{\ell-1,0.05} \times s_{\bar{x}} / \sqrt{\ell}$ (ℓ = number of laboratories)*4 $s_{\bar{x}_{ZrO_2}} = \sqrt{\left(s_{\bar{x}_{ZrO_2(+HfO_2)}}\right)^2 + \left(s_{\bar{x}_{HfO_2}}\right)^2}$

(1) List of laboratories : Kurosaki Corporation, Kawasaki Refractories Co.,Ltd., Yotai Refractories Co.,Ltd., Asahi Glass Co.,Ltd., Harima Ceramic Co.,Ltd., Shinagawa Refractories Co.,Ltd., Toshiba Ceramics Co.,Ltd., Toshiba Monofrax Co.,Ltd.

(2) Analytical techniques : JIS R 2013(Method for chemical analysis of refractory containing alumina, zirconia and silica) a:AAS, c:colorimetry, e:ionexchange-chelatometry, f:flametry, g:Cupfron Gravimetry, h:dehydration+colorimetry, i:ICP-AES, m:Mandelic acid Gravimetry, p:coagulation+colorimetry, v:Cupfron Separation-chelatometry, x:XRF

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Certified Reference Material Series for X-ray Fluorescence Analysis of Refractories

J R R M 7 0 3 (Alumina-Zirconia-Silica Refractory)

Results of Analyses

Unit : mass%

Constituent	SiO ₂	Al ₂ O ₃	Fe ₂ O ₃	TiO ₂	CaO	MgO	Na ₂ O	K ₂ O	Cr ₂ O ₃	ZrO ₂ (+HfO ₂)	HfO ₂	ZrO ₂ *3	Uncertified value	
													MnO	P ₂ O ₅
Certified value	14.6 ₆	46.3 ₉	0.05 ₉	0.07 ₂	0.03 ₇	0.01 ₁	0.53 ₅	0.00 ₂	0.00 ₆	38.1 ₂	0.72 ₈	37.3 ₈	0.00 ₀	0.03 ₅
Laboratories														
L ₁	14.5 _{1 p}	46.6 _{3 a}	0.05 _{8 i}	0.07 _{0 i}	0.03 _{6 i}	0.01 _{2 i}	0.52 _{2 a}	0.00 _{1 a}	0.01 _{0 i}	38.2 _{2 m}	0.71 _{9 z}	—	0.00 _{0 i}	0.03 _{7 c}
L ₂	14.6 _{0 p}	46.2 _{8 a}	0.06 _{0 c}	0.07 _{3 c}	0.03 _{5 i}	0.00 _{8 i}	0.53 _{2 f}	0.00 _{0 f}	0.00 _{4 i}	37.9 _{1 m}	0.70 _{3 i}	—	0.00 _{0 i}	0.03 _{4 c}
L ₃	14.7 _{7 h}	46.3 ₄	0.06 _{4 c}	0.08 _{1 c}	0.03 _{8 a}	0.01 _{4 a}	0.53 _{8 a}	0.00 _{2 a}	0.02 _{2 a}	38.3 _{0 m}	0.70 _{8 x}	—	—	—
L ₄	14.5 _{8 p}	46.2 _{2 v}	0.05 _{6 i}	0.06 _{1 i}	0.04 _{1 i}	0.01 _{1 i}	0.55 _{0 a}	0.00 _{0 a}	0.00 _{0 i}	38.2 _{0 m}	0.74 _{3 i}	—	0.00 _{1 i}	—
L ₅	14.5 _{8 h}	46.4 _{4 e}	0.06 _{0 c}	0.06 _{6 c}	0.03 _{5 a}	0.01 _{0 a}	0.54 _{6 a}	0.00 _{1 a}	0.00 _{2 a}	38.1 _{6 m}	0.71 _{3 z}	—	0.00 _{0 a}	0.03 _{2 c}
L ₆	14.6 _{0 h}	46.2 _{0 c}	0.05 _{4 c}	0.07 _{2 c}	0.04 _{0 i}	0.01 _{1 i}	0.52 _{0 a}	0.00 _{0 a}	0.00 _{0 a}	38.0 _{3 m}	0.74 _{0 i}	—	0.00 _{0 i}	0.04 _{0 c}
L ₇	14.8 _{0 p}	46.5 _{1 e}	0.05 _{8 c}	0.08 _{3 c}	0.03 _{4 a}	0.01 _{0 i}	0.53 _{0 a}	0.00 _{1 a}	0.00 _{4 a}	38.0 _{0 g}	0.74 _{2 i}	—	—	—
L ₈	14.6 _{1 p}	46.4 _{4 v}	0.06 _{2 c}	0.06 _{7 c}	0.03 _{8 a}	0.01 _{1 a}	0.53 _{6 a}	0.00 _{2 a}	0.00 _{4 a}	38.1 _{0 m}	0.75 _{3 z}	—	0.00 _{0 a}	0.03 _{0 c}
Average (\bar{X})	14.66 ₀	46.38 ₉	0.058 ₅	0.072 ₀	0.037 ₃	0.011 ₃	0.535 ₃	0.002 ₄	0.005 ₅	38.11 ₅	0.727 ₈	37.38 ₇	0.000 ₂	0.034 ₅
Standard deviation (Reproducibility) s_x	0.12 ₁	0.14 ₃	0.003 ₄	0.006 ₇	0.002 ₅	0.002 ₀	0.012 ₂	0.002 ₁	0.008 ₁	0.13 ₁	0.018 ₅	—	0.000 ₉	0.004 ₁
deviation (Reproducibility without laboratories) $s_{I(T)}^{*1}$	0.08 ₇	0.07 ₈	0.001 ₉	0.003 ₀	0.005 ₂	0.001 ₃	0.005 ₀	0.001 ₉	0.004 ₀	0.08 ₆	0.006 ₂	—	0.000 ₃	0.001 ₁
Uncertainty C (95%) *2	0.1 ₀	0.1 ₂	0.00 ₃	0.00 ₅	0.00 ₂	0.00 ₂	0.01 ₀	0.00 ₂	0.00 ₇	0.1 ₁	0.01 ₅	0.1 ₁ *4	0.00 ₁	0.00 ₅

(Note) * 1 $s_{I(T)}$ is intermediate precision without a time condition.* 3 $ZrO_2 = ZrO_2(+HfO_2) - HfO_2$ * 2 The half-width confidence interval C (95%) = $t_{\ell-1, 0.05} \times s_x / \sqrt{\ell}$ (ℓ = number of laboratories)* 4 $s_{x,ZO_2} = \sqrt{(s_{x,ZrO_2(+HfO_2)})^2 + (s_{x,HfO_2})^2}$

(1) List of laboratories : Kurosaki Corporation, Kawasaki Refractories Co.,Ltd., Yotai Refractories Co.,Ltd., Asahi Glass Co.,Ltd., Harima Ceramic Co.,Ltd., Shinagawa Refractories Co.,Ltd., Toshiba Ceramics Co.,Ltd., Toshiba Monofrax Co.,Ltd.

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J R R M 7 0 4 (Alumina-Zirconia-Silica Refractory)

Results of Analyses

Unit : mass%

Constituent		SiO ₂	Al ₂ O ₃	Fe ₂ O ₃	TiO ₂	CaO	MgO	Na ₂ O	K ₂ O	Cr ₂ O ₃	ZrO ₂ (+HfO ₂)	HfO ₂	ZrO ₂ *3	Uncertified value	
														MnO	P ₂ O ₅
Certified value		42.6 ₄	19.5 ₉	0.55 ₄	1.02 ₆	0.15 ₃	0.51 ₁	0.22 ₃	0.40 ₂	0.51 ₃	34.1 ₃	0.68 ₁	33.4 ₃	0.08 ₁	0.13 ₆
Laboratories	L ₁	42.4 _{2 p}	19.7 _{1 c}	0.55 _{9 i}	1.03 _{2 i}	0.14 _{3 i}	0.49 _{4 i}	0.22 _{2 n}	0.40 _{0 n}	0.50 _{3 i}	34.2 _{9 m}	0.67 _{0 x}	—	0.09 _{2 i}	0.13 _{3 c}
	L ₂	42.7 _{4 p}	19.5 _{0 c}	0.55 _{2 c}	1.01 _{1 i}	0.14 _{0 i}	0.51 _{3 i}	0.23 _{4 f}	0.40 _{2 f}	0.51 _{1 i}	34.0 _{9 m}	0.68 _{9 i}	—	0.09 _{4 i}	0.11 _{1 c}
	L ₃	42.7 _{2 h}	19.5 ₇	0.55 _{3 c}	1.03 _{0 c}	0.16 _{4 n}	0.51 _{1 n}	0.22 _{0 n}	0.39 _{2 n}	0.51 _{1 n}	34.3 _{2 m}	0.65 _{9 x}	—	—	—
	L ₄	42.4 _{2 p}	19.5 _{7 n}	0.54 _{1 i}	1.03 _{3 i}	0.16 _{2 i}	0.53 _{3 i}	0.24 _{4 n}	0.40 _{4 n}	0.50 _{8 i}	34.1 _{7 m}	0.69 _{3 i}	—	0.09 _{9 i}	—
	L ₅	42.7 _{3 h}	19.5 _{0 c}	0.55 _{9 c}	1.03 _{1 c}	0.15 _{2 n}	0.51 _{2 n}	0.21 _{0 n}	0.40 _{2 n}	0.54 _{1 n}	34.1 _{6 m}	0.69 _{7 x}	—	0.05 _{3 n}	0.11 _{2 c}
	L ₆	42.6 _{9 h}	19.5 _{3 c}	0.56 _{0 c}	1.03 _{4 i}	0.15 _{3 i}	0.51 _{0 i}	0.22 _{6 n}	0.40 _{2 n}	0.51 _{3 i}	34.1 _{2 m}	0.68 _{3 i}	—	0.09 _{1 i}	0.17 _{2 c}
	L ₇	42.7 _{0 p}	19.7 _{2 c}	0.56 _{6 c}	1.01 _{7 x}	0.15 _{2 n}	0.51 _{2 i}	0.23 _{6 n}	0.41 _{0 n}	0.53 _{2 n}	34.1 _{0 g}	0.69 _{3 i}	—	—	—
	L ₈	42.6 _{5 p}	19.6 _{5 v}	0.55 _{0 c}	1.02 _{0 c}	0.15 _{1 n}	0.52 _{8 n}	0.22 _{4 n}	0.40 _{0 n}	0.51 _{3 n}	34.0 _{6 m}	0.69 _{0 x}	—	0.09 _{5 n}	0.11 _{6 c}
Average (X̄)		42.64 ₁	19.59 ₄	0.553 ₉	1.026 ₀	0.154 ₉	0.515 ₀	0.228 ₁	0.402 ₃	0.517 ₃	34.16 ₄	0.684 ₉	33.47 ₉	0.088 ₃	0.130 ₄
Standard deviation	(Reproducibility) s _x	0.11 ₃	0.09 ₁	0.007 ₆	0.008 ₅	0.006 ₁	0.011 ₃	0.010 ₂	0.004 ₃	0.012 ₃	0.09 ₃	0.014 ₀	—	0.015 ₂	0.025 ₉
	(Reproducibility without laboratories) s _{I(T)} *1	0.08 ₃	0.10 ₂	0.006 ₄	0.007 ₁	0.004 ₀	0.004 ₃	0.005 ₄	0.005 ₃	0.008 ₃	0.10 ₇	0.006 ₇	—	0.001 ₃	0.003 ₂
Uncertainty C (95%) *2		0.1 ₀	0.0 ₇	0.00 ₃	0.00 ₇	0.00 ₃	0.01 ₀	0.00 ₃	0.004 ₀	0.01 ₀	0.0 ₃	0.01 ₁	0.0 ₃ *4	0.01 ₂	0.02 ₁

(Note) *1 $s_{I(T)}$ is intermediate precision without a time condition.*3 $ZrO_2 = ZrO_2(+HfO_2) - HfO_2$ *2 The half-width confidence interval C (95%) = $t_{\ell-1,0.05} \times s_x / \sqrt{\ell}$ (ℓ = number of laboratories)*4 $s_{x_{ZrO_2}} = \sqrt{(s_{x_{ZrO_2}(HfO_2)})^2 + (s_{x_{HfO_2}})^2}$

(1) List of laboratories : Kurosaki Corporation, Kawasaki Refractories Co.,Ltd., Yotai Refractories Co.,Ltd., Asahi Glass Co.,Ltd., Harima Ceramic Co.,Ltd., Shinagawa Refractories Co.,Ltd., Toshiba Ceramics Co.,Ltd., Toshiba Monofrax Co.,Ltd.

(2) Analytical techniques : JIS R 2013(Method for chemical analysis of refractory containing alumina, zirconia and silica) a:AAS, c:colorimetry, e:Ionexchange-chelatometry, f:flametry, g:Cupfron Gravimetry, h:dehydration+colorimetry, i:ICP-AES, m:Mandelic acid Gravimetry, p:coagulation+colorimetry, v:Cupfron Separation-chelatometry, x:XRF

(3) Analytical values : Each value is the average of two values obtained by two measurements on different days. These analysis values are shown converted into LOI (Loss on ignition) component free values from the February 22, 2008 v20080222 version on.

(4) Outlier tests were carried out by Grubbs test. The samples rejected by Grubbs tests were discussed in view of analytical techniques and it was determined whether the outliers should be adopted or not.

(5) Date of preparation : June, 1996

Prepared, and Values given and certified by

The Technical Association of Refractories, Japan
New Ginza Bldg., 3-13, Ginza 7-chome, Chuo-ku, Tokyo 104-0061, Japan
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The Technical Association of Refractories, Japan

Certified Reference Material Series for X-ray Fluorescence Analysis of Refractories

J R R M 7 0 5 (Alumina-Zirconia-Silica Refractory)

Results of Analyses

Unit : mass%

Constituent	SiO ₂	Al ₂ O ₃	Fe ₂ O ₃	TiO ₂	CaO	MgO	Na ₂ O	K ₂ O	Cr ₂ O ₃	ZrO ₂ (+HfO ₂)	HfO ₂	ZrO ₂ *3	Uncertified value	
													MnO	P ₂ O ₅
Certified value	2.00 ₂	64.2 ₄	0.14 ₁	2.02 ₄	0.19 ₁	0.46 ₁	0.30 ₁	0.01 ₂	2.02 ₂	28.5 ₀	0.48 ₅	28.0 ₁	0.00 ₄	0.01 ₇
Laboratories L ₁	2.00 _{4 c}	64.2 _{5 c}	0.13 _{1 i}	2.04 _{0 i}	0.19 _{1 i}	0.45 _{3 i}	0.28 _{0 n}	0.01 _{0 n}	2.02 _{0 i}	28.3 _{5 m}	0.47 _{9 z}	—	0.00 _{4 i}	0.04 _{0 c}
L ₂	1.97 _{4 c}	64.1 _{3 c}	0.14 _{0 c}	2.02 _{9 i}	0.18 _{0 i}	0.46 _{0 i}	0.30 _{0 f}	0.01 _{8 f}	2.01 _{0 i}	28.5 _{4 m}	0.48 _{7 z}	—	0.00 _{5 i}	0.01 _{1 c}
L ₃	2.01 _{1 h}	64.0 ₅	0.14 _{4 c}	2.03 _{5 c}	0.20 _{0 n}	0.46 _{1 n}	0.32 _{0 n}	0.02 _{3 n}	1.99 _{6 n}	28.6 _{6 m}	0.47 _{2 z}	—	—	—
L ₄	1.93 _{7 p}	64.1 _{5 c}	0.14 _{3 i}	2.04 _{5 i}	0.19 _{8 i}	0.48 _{3 i}	0.30 _{3 n}	0.01 _{9 n}	2.03 _{1 i}	28.7 _{3 m}	0.50 _{4 i}	—	0.00 _{6 i}	—
L ₅	2.08 _{5 c}	64.3 _{2 c}	0.13 _{0 c}	1.97 _{0 c}	0.18 _{2 n}	0.45 _{7 n}	0.28 _{9 n}	0.01 _{8 n}	2.02 _{9 n}	28.4 _{0 m}	0.47 _{1 z}	—	0.00 _{0 n}	0.01 _{1 c}
L ₆	2.06 _{5 c}	64.4 _{2 c}	0.13 _{1 c}	2.04 _{5 i}	0.19 _{9 i}	0.46 _{7 i}	0.29 _{9 n}	0.01 _{4 n}	2.01 _{6 i}	28.4 _{1 m}	0.48 _{3 i}	—	0.00 _{4 i}	0.01 _{2 c}
L ₇	2.01 _{0 c}	64.4 _{0 c}	0.15 _{0 c}	1.99 _{4 z}	0.18 _{1 n}	0.45 _{4 n}	0.31 _{3 n}	0.01 _{8 n}	2.03 _{7 n}	28.5 _{1 m}	0.48 _{7 i}	—	—	—
L ₈	1.93 _{1 c}	64.1 _{2 v}	0.15 _{2 c}	2.02 _{0 c}	0.18 _{5 n}	0.44 _{1 n}	0.29 _{6 n}	0.01 _{8 n}	2.02 _{1 n}	28.3 _{7 m}	0.49 _{0 z}	—	0.00 _{6 n}	0.01 _{2 c}
Average (\bar{X})	2.002 ₃	64.24 ₁	0.141 ₃	2.024 ₁	0.191 ₃	0.460 ₉	0.300 ₈	0.018 ₄	2.022 ₃	28.49 ₅	0.484 ₈	28.01 ₁	0.004 ₂	0.017 ₂
Standard deviation (Reproducibility) s_x	0.054 ₆	0.13 ₇	0.007 ₈	0.028 ₈	0.009 ₇	0.012 ₃	0.014 ₀	0.002 ₄	0.012 ₆	0.14 ₄	0.011 ₂	—	0.002 ₀	0.012 ₅
deviation (Reproducibility without laboratories) $s_{I(T)}^{*1}$	0.061 ₆	0.11 ₄	0.003 ₀	0.008 ₀	0.002 ₄	0.006 ₆	0.005 ₃	0.001 ₇	0.010 ₈	0.08 ₃	0.004 ₂	—	0.000 ₈	0.001 ₂
Uncertainty C (95%) *2	0.04 ₆	0.1 ₁	0.00 ₇	0.02 ₄	0.00 ₈	0.01 ₀	0.01 ₂	0.00 ₂	0.01 ₁	0.1 ₂	0.00 ₉	0.1 ₂ *4	0.00 ₂	0.01 ₆

(Note) * 1 $s_{I(T)}$ is intermediate precision without a time condition.* 2 The half-width confidence interval C (95%) = $t_{\ell-1,0.05} \times s_x / \sqrt{\ell}$ (ℓ = number of laboratories)* 3 $ZrO_2 = ZrO_2(+HfO_2) - HfO_2$ * 4 $s_{x,ZrO_2} = \sqrt{(s_{x,ZrO_2(HfO_2)})^2 + (s_{x,HfO_2})^2}$

(1) List of laboratories : Kurosaki Corporation, Kawasaki Refractories Co.,Ltd., Yotai Refractories Co.,Ltd., Asahi Glass Co.,Ltd., Harima Ceramic Co.,Ltd., Shinagawa Refractories Co.,Ltd., Toshiba Ceramics Co.,Ltd., Toshiba Monofrax Co.,Ltd.

(2) Analytical techniques : JIS R 2013(Method for chemical analysis of refractory containing alumina, zirconia and silica) a:AAS, c:colorimetry, e:Ionexchange-chelatometry, f:flametry, g:Cupfron Gravimetry, h:dehydration+colorimetry, i:ICP-AES, m:Mandelic acid Gravimetry, p:coagulation+colorimetry, v:Cupfron Separation-chelatometry, x:XRF

(3) Analytical values : Each value is the average of two values obtained by two measurements on different days. These analysis values are shown converted into LOI (Loss on ignition) component free values from the February 22, 2008 v20080222 version on.

(4) Outlier tests were carried out by Grubbs test. The samples rejected by Grubbs tests were discussed in view of analytical techniques and it was determined whether the outliers should be adopted or not.

(5) Date of preparation : June, 1996

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The Technical Association of Refractories, Japan

Certified Reference Material Series for X-ray Fluorescence Analysis of Refractories

J R R M 7 0 6 (Alumina-Zirconia-Silica Refractory)

Results of Analyses

Unit : mass%

Constituent	SiO ₂	Al ₂ O ₃	Fe ₂ O ₃	TiO ₂	CaO	MgO	Na ₂ O	K ₂ O	Cr ₂ O ₃	ZrO ₂ (+HfO ₂)	HfO ₂	ZrO ₂ *3	Uncertified value		
													MnO	P ₂ O ₅	
Certified value	39.6 ₂	26.1 ₄	0.13 ₁	3.80 ₅	1.59 ₈	0.15 ₃	3.52 ₁	0.95 ₉	0.01 ₀	24.0 ₉	1.19 ₉	22.8 ₉	0.00 ₄	0.01 ₅	
Laboratories	L ₁	39.6 _{3 p}	26.1 _{5 e}	0.13 _{1 i}	3.77 _{9 i}	1.61 _{6 i}	0.16 _{3 i}	3.51 _{3 a}	0.97 _{1 a}	0.01 _{0 i}	24.1 _{2 m}	1.19 _{7 x}	—	0.00 _{6 i}	0.01 _{7 c}
	L ₂	39.6 _{3 p}	26.0 _{9 e}	0.13 _{1 e}	3.81 _{0 x}	1.59 _{2 i}	0.15 _{9 i}	3.56 _{8 f}	0.96 _{9 f}	0.01 _{1 i}	24.0 _{1 m}	1.13 _{4 i}	—	0.00 _{4 i}	0.01 _{6 e}
	L ₃	39.6 _{5 p}	26.1 _{6 e}	0.12 _{9 e}	3.78 _{9 i}	1.61 _{7 i}	0.16 _{1 i}	3.49 _{8 a}	0.97 _{2 a}	0.00 _{8 i}	24.0 _{7 m}	1.19 _{1 i}	—	0.00 _{6 i}	0.01 _{4 e}
	L ₄	39.5 _{9 h}	26.2 ₅	0.13 _{0 e}	3.82 _{2 x}	1.58 _{8 a}	0.14 _{6 a}	3.51 _{1 a}	0.96 _{3 a}	0.00 _{8 a}	24.0 _{0 m}	1.18 _{3 x}	—	—	—
	L ₅	39.5 _{7 p}	26.1 _{0 e}	0.13 _{1 i}	3.81 _{0 i}	1.59 _{0 i}	0.15 _{9 i}	3.54 _{5 a}	0.95 _{7 a}	0.01 _{2 i}	24.0 _{2 m}	1.20 _{8 i}	—	0.00 _{5 i}	—
	L ₆	39.6 _{1 h}	26.0 _{6 e}	0.13 _{0 e}	3.78 _{9 x}	1.59 _{8 a}	0.16 _{1 a}	3.49 _{9 a}	0.95 _{1 a}	0.01 _{0 a}	24.0 _{5 m}	1.23 _{3 x}	—	0.00 _{2 a}	0.01 _{7 c}
	L ₇	39.6 _{3 h}	26.2 _{0 e}	0.12 _{0 e}	3.82 _{0 e}	1.61 _{1 i}	0.16 _{0 i}	3.50 _{6 a}	0.94 _{3 a}	0.00 _{8 a}	24.1 _{2 m}	1.21 _{2 i}	—	0.00 _{1 i}	0.01 _{8 e}
	L ₈	39.6 _{1 p}	26.1 _{3 e}	0.13 _{3 e}	3.80 _{9 x}	1.58 _{2 a}	0.15 _{9 a}	3.52 _{0 a}	0.94 _{3 a}	0.00 _{6 a}	24.2 _{4 m}	1.23 _{5 x}	—	0.00 _{3 a}	0.01 _{1 e}
Average (X̄)	39.61 ₅	26.14 ₃	0.131 ₀	3.806 ₁	1.598 ₈	0.159 ₃	3.521 ₄	0.958 ₉	0.009 ₅	24.08 ₆	1.199 ₁	22.88 ₇	0.003 ₉	0.015 ₅	
Standard deviation	(Reproducibility) s _{x̄}	0.03 ₀	0.06 ₄	0.002 ₀	0.019 ₂	0.013 ₀	0.006 ₂	0.024 ₃	0.011 ₇	0.001 ₅	0.07 ₉	0.032 ₁	—	0.002 ₀	0.002 ₅
	(Reproducibility without laboratories) s _{I(T)} *1	0.08 ₄	0.07 ₃	0.001 ₇	0.010 ₉	0.008 ₂	0.004 ₀	0.016 ₈	0.004 ₄	0.001 ₅	0.06 ₅	0.012 ₈	—	0.000 ₅	0.001 ₆
Uncertainty C (95%) *2	0.0 ₃	0.0 ₅	0.00 ₂	0.01 ₈	0.01 ₁	0.00 ₅	0.02 ₀	0.01 ₀	0.00 ₁	0.0 ₁	0.02 ₇	0.0 ₇ *4	0.00 ₂	0.00 ₃	

(Note) * 1 $s_{I(T)}$ is intermediate precision without a time condition.* 3 $ZrO_2 = ZrO_2 + (HfO_2) - HfO_2$ * 2 The halfwidth confidence interval C (95%) = $t_{\ell-1, 0.05} \times s_x / \sqrt{\ell}$ (ℓ = number of laboratories)* 4 $s_{x, 2\sigma} = \sqrt{\left(s_{x, ZrO_2 + HfO_2}\right)^2 + \left(s_{x, HfO_2}\right)^2}$

(1) List of laboratories : Kurosaki Corporation, Kawasaki Refractories Co., Ltd., Yotai Refractories Co., Ltd., Asahi Glass Co., Ltd., Harima Ceramic Co., Ltd., Shinagawa Refractories Co., Ltd., Toshiba Ceramics Co., Ltd., Toshiba Monofrax Co., Ltd.

(2) Analytical techniques : JIS R 2013 (Method for chemical analysis of refractory containing alumina, zirconia and silica) a: AAS, c: colorimetry, e: Ion exchange-chelatometry, f: flameometry, g: Cupfron Gravimetry, h: dehydration + colorimetry, i: ICP-AES, m: Mandelic acid Gravimetry, p: coagulation + colorimetry, v: Cupfron Separation-chelatometry, x: XRF

(3) Analytical values : Each value is the average of two values obtained by two measurements on different days. These analysis values are shown converted into LOI (Loss on ignition) component free values from the February 22, 2008 v20080222 version on.

(4) Outlier tests were carried out by Grubbs test. The samples rejected by Grubbs tests were discussed in view of analytical techniques and it was determined whether the outliers should be adopted or not.

(5) Date of preparation : June, 1996

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The Technical Association of Refractories, Japan

Certified Reference Material Series for X-ray Fluorescence Analysis of Refractories

J RRM 707 (Alumina-Zirconia-Silica Refractory)

Results of Analyses

Unit : mass%

Unit: mass %															
Constituent	SiO ₂	Al ₂ O ₃	Fe ₂ O ₃	TiO ₂	CaO	MgO	Na ₂ O	K ₂ O	Cr ₂ O ₃	ZrO ₂ (+HfO ₂)	HfO ₂	ZrO ₂ *3	Uncertified value		
													MnO	P ₂ O ₅	
Certified value	21.1 ₇	55.7 ₈	1.81 ₅	0.28 ₉	1.08 ₈	0.84 ₄	0.19 ₉	0.15 ₃	0.18 ₀	18.5 ₃	0.36 ₇	18.1 ₈	0.00 ₃	0.05 ₅	
Laboratories	L ₁	21.1 _{8 p}	55.6 _{9 v}	1.83 _{2 i}	0.28 _{5 i}	1.09 _{1 i}	0.84 _{6 i}	0.20 _{2 n}	0.15 _{4 n}	0.18 _{3 i}	18.5 _{2 m}	0.36 _{3 x}	—	0.00 _{5 i}	0.05 _{2 c}
	L ₂	21.2 _{0 p}	55.7 _{0 v}	1.81 _{2 c}	0.28 _{3 i}	1.08 _{3 i}	0.84 _{6 i}	0.19 _{3 f}	0.15 _{9 f}	0.17 _{6 i}	18.4 _{4 m}	0.37 _{6 i}	—	0.00 _{4 i}	0.05 _{5 c}
	L ₃	21.0 _{4 p}	55.8 _{3 v}	1.80 _{8 v}	0.29 _{2 i}	1.09 _{2 i}	0.84 _{1 i}	0.20 _{4 n}	0.15 _{0 n}	0.17 _{9 i}	18.4 _{6 m}	0.37 _{2 i}	—	0.00 _{4 i}	0.05 _{6 c}
	L ₄	21.2 _{5 h}	55.7 ₉	1.80 _{7 c}	0.29 _{0 c}	1.08 _{2 n}	0.84 _{8 n}	0.20 _{8 n}	0.15 _{4 n}	0.17 _{8 n}	18.7 _{3 m}	0.34 _{9 x}	—	—	—
	L ₅	21.1 _{9 p}	55.7 _{6 v}	1.82 _{0 i}	0.29 _{0 i}	1.07 _{8 i}	0.84 _{6 i}	0.20 _{6 n}	0.15 _{6 n}	0.17 _{4 i}	18.4 _{7 m}	0.37 _{3 i}	—	0.00 _{4 i}	—
	L ₆	21.2 _{7 h}	55.8 _{8 v}	1.82 _{0 c}	0.29 _{1 c}	1.08 _{1 n}	0.84 _{4 n}	0.20 _{3 n}	0.15 _{2 n}	0.18 _{2 n}	18.4 _{6 m}	0.35 _{4 x}	—	0.00 _{2 n}	0.05 _{6 c}
	L ₇	21.0 _{2 h}	55.8 _{0 v}	1.82 _{6 c}	0.29 _{4 c}	1.09 _{3 i}	0.84 _{1 i}	0.17 _{7 n}	0.15 _{3 n}	0.18 _{2 i}	18.4 _{8 m}	0.37 _{6 i}	—	0.00 _{1 i}	0.05 _{6 c}
	L ₈	21.2 _{2 p}	55.7 _{7 v}	1.79 _{4 c}	0.282	1.08 _{0 n}	0.84 _{2 n}	0.20 _{0 n}	0.16 _{0 n}	0.18 _{4 n}	18.6 _{6 m}	0.37 _{4 x}	—	0.00 _{2 n}	0.05 _{3 c}
Average $\langle \bar{X} \rangle$	21.16 ₉	55.78 ₄	1.814 ₉	0.288 ₆	1.085 ₆	0.844 ₄	0.199 ₁	0.154 ₄	0.179 ₈	18.52 ₅	0.367 ₄	18.15 ₉	0.003 ₁	0.055 ₀	
Standard deviation (without laboratories)	(Reproducibility) $s_{\bar{x}}$	0.09 ₃	0.07 ₄	0.012 ₂	0.004 ₂	0.006 ₄	0.002 ₉	0.009 ₉	0.003 ₃	0.003 ₅	0.10 ₈	0.011 ₀	—	0.001 ₅	0.002 ₃
	(Reproducibility) $s_{I(T)}$ *1	0.04 ₃	0.12 ₄	0.007 ₉	0.002 ₃	0.006 ₄	0.007 ₁	0.002 ₅	0.004 ₄	0.002 ₇	0.07 ₄	0.005 ₁	—	0.001 ₂	0.001 ₂
Uncertainty C (95%) *2	0.0 ₈	0.0 ₆	0.01 ₀	0.00 ₄	0.00 ₅	0.00 ₂	0.00 ₆	0.00 ₃	0.00 ₃	0.0 ₉	0.00 ₉	0.0 ₀ *4	0.00 ₂	0.00 ₂	

(Note) * 1 $s_{I(T)}$ is intermediate precision without a time condition.* 3 $ZrO_2 = ZrO_2(+HfO_2) - HfO_2$ * 2 The half-width confidence interval C (95%) = $t_{\ell-1,0.05} \times s_{\bar{x}} / \sqrt{\ell}$ (ℓ = number of laboratories)* 4 $s_{x,2D,1} = \sqrt{\left(s_{x,ZrO_2(HfO_2)}\right)^2 + \left(s_{x,HfO_2}\right)^2}$

(1) List of laboratories : Kurosaki Corporation, Kawasaki Refractories Co.,Ltd., Yotai Refractories Co.,Ltd., Asahi Glass Co.,Ltd., Harima Ceramic Co.,Ltd., Shinagawa Refractories Co.,Ltd., Toshiba Ceramics Co.,Ltd., Toshiba Monofrax Co.,Ltd.

(2) Analytical techniques : JIS R 2013(Method for chemical analysis of refractory containing alumina, zirconia and silica) a:AAS, c:colorimetry, e:Ionexchange-chelatometry, f:flametry, g:Cupfron Gravimetry, h:dehydration+colorimetry, i:ICP-AES, m:Mandelic acid Gravimetry, p:coagulation+colorimetry, v:Cupfron Separation-chelatometry, x:XRF

(3) Analytical values : Each value is the average of two values obtained by two measurements on different days. These analysis values are shown converted into LOI (Loss on ignition) component free values from the February 22, 2008 v20080222 version on.

(4) Outlier tests were carried out by Grubbs test. The samples rejected by Grubbs tests were discussed in view of analytical techniques and it was determined whether the outliers should be adopted or not.

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The Technical Association of Refractories, Japan

Certified Reference Material Series for X-ray Fluorescence Analysis of Refractories

J R R M 7 0 8 (Alumina-Zirconia-Silica Refractory)

Results of Analyses

Unit : mass%

Constituent		SiO ₂	Al ₂ O ₃	Fe ₂ O ₃	TiO ₂	CaO	MgO	Na ₂ O	K ₂ O	Cr ₂ O ₃	ZrO ₂ (+HfO ₂)	HfO ₂	ZrO ₂ *3	Uncertified value	
														MnO	P ₂ O ₅
Certified value		0.54 ₇	79.6 ₃	0.80 ₁	1.02 ₁	1.17 ₄	1.64 ₉	0.08 ₉	0.74 ₆	0.29 ₉	13.8 ₉	1.03 ₄	12.8 ₉	0.00 ₁	0.00 ₂
Laboratories	L ₁	0.54 _{7 c}	79.5 _{0 c}	0.80 _{5 i}	1.00 _{1 i}	1.18 _{2 i}	1.66 _{1 i}	0.07 _{4 n}	0.72 _{3 n}	0.29 _{8 i}	13.9 _{1 m}	1.01 _{9 s}	—	0.00 _{2 i}	0.00 _{2 c}
	L ₂	0.56 _{3 c}	79.7 _{2 s}	0.80 _{0 c}	1.03 _{3 s}	1.18 _{3 i}	1.66 _{1 i}	0.09 _{4 f}	0.75 _{4 f}	0.29 _{1 i}	13.9 _{6 m}	1.06 _{3 i}	—	0.00 _{1 i}	0.00 _{2 c}
	L ₃	0.54 _{3 c}	79.6 _{7 n}	0.80 _{1 c}	1.01 _{1 i}	1.18 _{3 i}	1.65 _{1 i}	0.08 _{7 n}	0.75 _{5 n}	0.29 _{9 i}	13.9 _{1 m}	1.03 _{2 i}	—	0.00 _{1 i}	0.00 _{3 c}
	L ₄	0.55 ₇	79.7 ₄	0.80 _{1 c}	1.03 _{3 s}	1.16 _{2 n}	1.64 _{1 n}	0.09 _{2 n}	0.75 _{1 n}	0.29 _{9 n}	13.8 _{0 m}	1.01 _{6 s}	—	—	—
	L ₅	0.55 _{9 n}	79.4 _{8 n}	0.79 _{1 i}	1.00 _{9 i}	1.15 _{1 i}	1.64 _{7 i}	0.09 _{6 n}	0.77 _{9 n}	0.29 _{7 i}	13.8 _{2 m}	1.03 _{9 i}	—	0.00 _{1 i}	—
	L ₆	0.54 _{7 c}	79.6 _{7 c}	0.79 _{7 c}	1.02 _{5 s}	1.18 _{3 n}	1.64 _{2 n}	0.09 _{1 n}	0.74 _{3 n}	0.29 _{9 n}	13.8 _{7 m}	1.01 _{9 s}	—	0.00 _{0 n}	0.00 _{2 c}
	L ₇	0.52 _{3 c}	79.6 _{1 c}	0.80 _{7 c}	1.03 _{1 i}	1.18 _{3 i}	1.64 _{6 i}	0.08 _{5 n}	0.74 _{3 n}	0.29 _{5 i}	13.9 _{6 m}	1.01 _{6 i}	—	0.00 _{0 i}	0.00 _{2 c}
	L ₈	0.53 _{6 c}	79.6 _{7 c}	0.80 _{1 c}	1.01 _{6 s}	1.15 _{1 n}	1.63 _{1 n}	0.09 _{0 n}	0.72 _{4 n}	0.30 _{0 n}	13.8 _{9 m}	1.06 _{3 s}	—	0.00 _{0 n}	0.00 _{0 c}
Average (X̄)		0.546 ₉	79.63 ₃	0.801 ₁	1.021 ₀	1.173 ₉	1.648 ₆	0.088 ₆	0.746 ₅	0.297 ₅	13.89 ₉	1.034 ₃	12.85 ₆	0.000 ₇	0.001 ₈
Standard deviation	(Reproducibility) s _{X̄}	0.013 ₉	0.10 ₅	0.005 ₃	0.013 ₂	0.015 ₄	0.010 ₉	0.006 ₇	0.018 ₉	0.002 ₁	0.05 ₉	0.021 ₅	—	0.000 ₇	0.000 ₈
	(Reproducibility without laboratories) s _{I(T)} *1	0.007 ₃	0.07 ₈	0.004 ₈	0.005 ₉	0.004 ₇	0.007 ₉	0.001 ₈	0.002 ₄	0.002 ₈	0.07 ₄	0.012 ₃	—	0.000 ₇	0.001 ₀
Uncertainty C (95%) *2		0.01 ₁	0.0 ₉	0.00 ₄	0.01 ₁	0.01 ₃	0.00 ₉	0.00 ₆	0.01 ₅	0.00 ₂	0.0 ₈	0.01 ₈	0.0 ₆ *4	0.00 ₁	0.00 ₁

(Note) * 1 $s_{I(T)}$ is intermediate precision without a time condition.* 3 $ZrO_2 = ZrO_2(+HfO_2) - HfO_2$ * 2 The half-width confidence interval C (95%) = $t_{\ell-1,0.05} \times s_{\bar{X}} / \sqrt{\ell}$ (ℓ = number of laboratories)* 4 $s_{\bar{X},ZrO_2} = \sqrt{\left(s_{\bar{X},ZrO_2(+HfO_2)}\right)^2 + \left(s_{\bar{X},HfO_2}\right)^2}$

(1) List of laboratories : Kurosaki Corporation, Kawasaki Refractories Co.,Ltd., Yotai Refractories Co.,Ltd., Asahi Glass Co.,Ltd., Harima Ceramic Co.,Ltd., Shinagawa Refractories Co.,Ltd., Toshiba Ceramics Co.,Ltd., Toshiba Monofrax Co.,Ltd.

(2) Analytical techniques : JIS R 2013(Method for chemical analysis of refractory containing alumina, zirconia and silica) a:AAS, c:colorimetry, e:Ionexchange-chelatometry, f:flametry, g:Cupfron Gravimetry, h:dehydration + colorimetry, i:ICP-AES, m:Mandelic acid Gravimetry, p:coagulation + colorimetry, v:Cupfron Separation-chelatometry, x:XRF

(3) Analytical values : Each value is the average of two values obtained by two measurements on different days. These analysis values are shown converted into LOI (Loss on ignition) component free values from the February 22, 2008 v20080222 version on.

(4) Outlier tests were carried out by Grubbs test. The samples rejected by Grubbs tests were discussed in view of analytical techniques and it was determined whether the outliers should be adopted or not.

(5) Date of preparation : June, 1996

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The Technical Association of Refractories, Japan

Certified Reference Material Series for X-ray Fluorescence Analysis of Refractories

J R R M 7 0 9 (Alumina-Zirconia-Silica Refractory)

Results of Analyses

Unit : mass%

Unit : mass %													Uncertified value		
Constituent	SiO ₂	Al ₂ O ₃	Fe ₂ O ₃	TiO ₂	CaO	MgO	Na ₂ O	K ₂ O	Cr ₂ O ₃	ZrO ₂ (+HfO ₂)	HfO ₂	ZrO ₂ *3	MnO	P ₂ O ₅	
Certified value	34.4 _s	50.4 _s	0.47 _t	0.09 _i	0.52 _s	1.21 _s	1.04 _s	0.21 _s	2.92 _z	8.52 _z	0.18 _t	8.34 _s	0.00 _z	0.00 _t	
Laboratories	L ₁	34.5 _{n p}	50.2 _{7 e}	0.47 _{2 i}	0.08 _{8 i}	0.52 _{5 i}	1.21 _{1 i}	1.01 _{0 n}	0.21 _{4 n}	2.93 _{3 i}	8.61 _{6 m}	0.17 _{6 x}	—	0.00 _{4 i}	0.01 _{0 c}
	L ₂	34.4 _{2 p}	50.4 _{3 e}	0.48 _{2 c}	0.08 _{8 i}	0.53 _{4 i}	1.20 _{0 i}	1.05 _{8 f}	0.21 _{8 f}	2.88 _{0 i}	8.50 _{8 m}	0.20 _{0 i}	—	0.00 _{2 i}	0.01 _{0 c}
	L ₃	34.4 _{8 p}	50.4 _{8 o}	0.47 _{4 c}	0.09 _{2 i}	0.52 _{1 i}	1.21 _{3 i}	1.04 _{0 e}	0.22 _{1 n}	2.93 _{0 i}	8.57 _{8 m}	0.19 _{0 i}	—	0.00 _{4 i}	0.00 _{8 c}
	L ₄	34.5 _{8 h}	50.5 ₀	0.47 _{3 c}	0.09 _{2 c}	0.51 _{9 n}	1.21 _{0 n}	1.03 _{0 n}	0.22 _{4 n}	2.94 _{3 n}	8.52 _{5 m}	0.15 _{8 x}	—	—	—
	L ₅	34.3 _{6 p}	50.4 _{3 n}	0.47 _{0 i}	0.09 _{1 i}	0.51 _{7 i}	1.20 _{0 i}	1.03 _{1 n}	0.21 _{4 n}	2.93 _{0 i}	8.51 _{2 m}	0.19 _{0 i}	—	0.00 _{4 i}	—
	L ₆	34.4 _{1 h}	50.4 _{6 c}	0.47 _{0 c}	0.09 _{2 c}	0.52 _{0 n}	1.20 _{3 n}	1.04 _{8 n}	0.21 _{8 n}	2.92 _{8 n}	8.52 _{5 m}	0.17 _{0 x}	—	0.00 _{1 n}	0.01 _{0 c}
	L ₇	34.3 _{0 h}	50.5 _{4 e}	0.47 _{7 c}	0.09 _{1 c}	0.51 _{5 i}	1.21 _{1 i}	1.03 _{4 n}	0.21 _{2 n}	2.91 _{4 i}	8.36 _{5 i}	0.19 _{3 i}	—	0.00 _{0 i}	0.01 _{0 c}
	L ₈	34.4 _{5 p}	50.4 _{7 e}	0.47 _{0 c}	0.08 _{8 c}	0.53 _{8 n}	1.21 _{0 n}	1.05 _{4 n}	0.20 _{0 n}	2.89 _{0 n}	8.55 _{8 m}	0.18 _{2 x}	—	0.00 _{2 n}	0.00 _{4 c}
Average (\bar{x})	34.45 ₃	50.45 ₀	0.476 ₉	0.091 ₀	0.525 ₁	1.210 ₅	1.040 ₀	0.216 ₃	2.922 ₃	8.523 ₃	0.183 ₅	8.339 ₉	0.002 ₄	0.008 ₇	
Standard deviation (Reproducibility) $s_{\bar{x}}$	0.07 ₀	0.08 ₃	0.003 ₆	0.003 ₁	0.008 ₅	0.004 ₀	0.013 ₅	0.004 ₈	0.021 ₀	0.072 ₀	0.012 ₈	—	0.001 ₁	0.002 ₅	
deviation (Reproducibility without laboratories) $s_{I(T)}^{*1}$	0.05 ₀	0.11 ₃	0.003 ₀	0.001 ₈	0.003 ₈	0.010 ₀	0.012 ₄	0.006 ₉	0.019 ₇	0.076 ₇	0.003 ₅	—	0.001 ₈	0.001 ₈	
Uncertainty C (95%) u_c^{*2}	0.0 _s	0.0 ₇	0.00 ₃	0.00 ₃	0.00 ₇	0.00 ₃	0.01 ₇	0.00 ₄	0.01 ₈	0.06 ₉	0.01 ₁	0.06 ₁ ^{*4}	0.00 ₁	0.00 ₃	

(Note) * 1 $s_{I(T)}$ is intermediate precision without a time condition.* 3 $ZrO_2 = ZrO_2(+HfO_2) - HfO_2$ * 2 The half-width confidence interval C (95%) = $t_{\ell-1,0.05} \times s_x / \sqrt{\ell}$ (ℓ = number of laboratories)* 4 $s_{x,ZrO_2} = \sqrt{(s_{x,ZrO_2(100\%)})^2 + (s_{x,HfO_2})^2}$

(1) List of laboratories : Kurosaki Corporation, Kawasaki Refractories Co.,Ltd., Yotai Refractories Co.,Ltd., Asahi Glass Co.,Ltd., Harima Ceramic Co.,Ltd., Shinagawa Refractories Co.,Ltd., Toshiba Ceramics Co.,Ltd., Toshiba Monofrax Co.,Ltd.

(2) Analytical techniques : JIS R 2013(Method for chemical analysis of refractory containing alumina, zirconia and silica) a:AAS, c:colorimetry, e:Ionexchange-chelatometry, f:flametry, g:Cupfron Gravimetry, h:dehydration+colorimetry, i:ICP-AES, m:Mandelic acid Gravimetry, p:coagulation+colorimetry, v:Cupfron Separation-chelatometry, x:XRF

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(4) Outlier tests were carried out by Grubbs test. The samples rejected by Grubbs tests were discussed in view of analytical techniques and it was determined whether the outliers should be adopted or not.

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Certified Reference Material Series for X-ray Fluorescence Analysis of Refractories

J R R M 7 1 0 (Alumina-Zirconia-Silica Refractory)

Results of Analyses

Unit : mass%

Constituent	SiO ₂	Al ₂ O ₃	Fe ₂ O ₃	TiO ₂	CaO	MgO	Na ₂ O	K ₂ O	Cr ₂ O ₃	ZrO ₂ (+HfO ₂)	HfO ₂	ZrO ₂ *3	Uncertified value	
													MnO	P ₂ O ₅
Certified value	5.62 ₉	82.3 ₆	1.15 ₁	3.00 ₅	0.22 ₅	0.04 ₅	1.42 ₁	0.63 ₇	1.02 ₈	4.47 ₉	1.51 ₂	2.96 ₇	0.00 ₂	0.04 ₂
Laboratories														
L ₁	5.49 _{7 p}	82.1 _{9 e}	1.16 _{1 i}	3.02 _{1 i}	0.22 _{5 i}	0.05 _{0 i}	1.39 _{0 n}	0.64 _{2 a}	1.04 _{1 i}	4.59 _{2 m}	1.51 _{1 x}	—	0.00 _{3 i}	0.04 _{1 e}
L ₂	5.59 _{8 p}	82.3 _{2 e}	1.19 _{7 e}	2.99 _{1 x}	0.22 _{1 i}	0.05 _{0 i}	1.46 _{0 f}	0.64 _{2 f}	1.05 _{9 i}	4.58 _{5 m}	1.52 _{4 x}	—	0.00 _{2 i}	0.04 _{2 e}
L ₃	5.65 _{7 c}	82.4 _{0 n}	1.14 _{9 e}	3.01 _{8 i}	0.22 _{5 i}	0.05 _{0 i}	1.42 _{1 n}	0.63 _{9 n}	1.02 _{3 i}	4.50 _{5 m}	1.50 _{0 i}	—	0.00 _{3 i}	0.04 _{1 e}
L ₄	5.68 _{8 h}	82.4 ₅	1.09 _{1 e}	3.02 _{3 x}	0.22 _{1 a}	0.04 _{0 n}	1.42 _{7 n}	0.63 _{2 a}	1.01 _{5 n}	4.46 _{0 m}	1.49 _{3 x}	—	—	—
L ₅	5.59 _{6 c}	82.3 _{8 n}	1.11 _{9 i}	2.96 _{0 i}	0.22 _{0 i}	0.04 _{0 i}	1.42 _{0 n}	0.64 _{0 n}	1.00 _{3 i}	4.27 _{0 m}	1.51 _{1 i}	—	0.00 _{3 i}	—
L ₆	5.79 _{5 c}	82.3 _{4 e}	1.15 _{9 e}	3.00 _{2 x}	0.23 _{0 n}	0.04 _{0 n}	1.41 _{5 n}	0.63 _{7 n}	1.02 _{3 n}	4.40 _{1 m}	1.50 _{0 x}	—	0.00 _{2 n}	0.04 _{0 e}
L ₇	5.76 _{0 c}	82.3 _{2 e}	1.15 _{0 e}	3.01 _{0 e}	0.22 _{1 i}	0.05 _{0 i}	1.40 _{3 n}	0.62 _{5 n}	1.01 _{7 i}	4.46 _{4 i}	1.47 _{9 i}	—	0.00 _{0 i}	0.04 _{1 e}
L ₈	5.44 _{1 e}	82.4 _{1 n}	1.17 _{1 e}	3.01 _{1 x}	0.22 _{1 n}	0.05 _{1 n}	1.41 _{3 n}	0.63 _{1 n}	1.04 _{1 n}	4.54 _{0 m}	1.56 _{0 x}	—	0.00 _{1 n}	0.04 _{1 e}
Average (\bar{X})	5.629 ₀	82.36 ₄	1.150 ₂	3.004 ₅	0.225 ₀	0.049 ₄	1.420 ₅	0.636 ₉	1.028 ₁	4.479 ₃	1.511 ₉	2.967 ₄	0.002 ₀	0.042 ₅
Standard deviation (Reproducibility) s_x	0.121 ₇	0.08 ₃	0.032 ₇	0.021 ₃	0.003 ₀	0.001 ₄	0.022 ₂	0.006 ₉	0.018 ₀	0.105 ₁	0.025 ₄	—	0.001 ₀	0.001 ₄
deviation (Reproducibility without laboratories) $s_{J(T)}^{*1}$	0.025 ₇	0.11 ₇	0.007 ₆	0.005 ₃	0.008 ₃	0.002 ₉	0.008 ₁	0.008 ₉	0.018 ₃	0.025 ₇	0.007 ₇	—	0.001 ₄	0.000 ₆
Uncertainty C (95%) *2	0.10 ₂	0.0 ₇	0.02 ₇	0.01 ₈	0.00 ₃	0.00 ₁	0.01 ₉	0.00 ₅	0.01 ₅	0.08 ₈	0.02 ₁	0.09 ₉ *4	0.00 ₁	0.00 ₂

(Note) * 1 $s_{J(T)}$ is intermediate precision without a time condition.* 3 $ZrO_2 = ZrO_2(+HfO_2) - HfO_2$ * 2 The half-width confidence interval C (95%) = $t_{\ell-1,0.05} \times s_x / \sqrt{\ell}$ (ℓ = number of laboratories)* 4 $s_{x,ZO_2} = \sqrt{(s_{x,ZO_2,UPV})^2 + (s_{x,HfO_2})^2}$

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